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Low-temperature synthesis of rhodium phosphide on alumina and investigation of its catalytic activity toward the hydrodesulfurization of thiophene

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Abstract

In this study, the low-temperature synthesis of rhodium phosphide (Rh\textsubscript{2}P) on alumina (Al\textsubscript{2}O\textsubscript{3}) using triphenylphosphine (TPP) as a phosphorus (P) source and its catalytic activity toward
hydrodesulfurization (HDS) were investigated to prepare a highly active HDS catalyst. TPP was more easily reduced than phosphate, and Rh$_2$P was formed in the P(T)/Rh/Al$_2$O$_3$ catalyst prepared from TTP at lower temperature as compared with the temperature required by Rh-P(A)/Al$_2$O$_3$ catalyst prepared from a phosphate precursor. However, after reduction at a low temperature (450 °C), excess P covered the surface of Rh$_2$P. The optimal reduction temperature for HDS rate of the P(T)/Rh/Al$_2$O$_3$ catalyst (650 °C) was lower than that of the Rh-P(A)/Al$_2$O$_3$ catalyst (800 °C). Furthermore, this temperature was slightly higher than the optimal reduction temperature for CO uptake (600 °C). These results are explained as follows: HDS rate is increased by both elimination of excess P on the active sites at higher reduction temperatures and enhancement of the crystallinity of Rh$_2$P. Furthermore, because the particle size of the P(T)/Rh/Al$_2$O$_3$ catalyst (ca. 1.2 nm) was substantially smaller than that of the Rh-P(A)/Al$_2$O$_3$ catalyst, the P(T)/Rh/Al$_2$O$_3$ catalyst exhibited greater HDS rate compared with the Rh-P(A)/Al$_2$O$_3$ catalyst.

**Keywords**
Rhodium phosphide catalyst; Alumina support; Hydrodesulfurization; Triphenylphosphine; Low-temperature synthesis

1. Introduction

Recently, the petroleum industry has claimed that the development of highly active hydrodesulfurization (HDS) catalysts that exhibit greater activity than commercial CoMo catalysts will prevent air pollution, acid rain, and the deactivation of automotive exhaust catalysts [1-3]. New active phases, especially nickel phosphide (Ni₂P), have received extensive attention [2-22]. Furthermore, our group [23-27] and Bussell’s group [3, 28] reported that rhodium phosphide (Rh₂P) supported on SiO₂ exhibits high and stable catalytic activity toward the HDS reaction.

Phosphate reduction is a convenient and simple method to prepare phosphide catalysts [16]. Because phosphate has strong P–O bonds, phosphate reduction requires high temperatures [3]. In general, SiO₂, which does not strongly interact with phosphate, is a suitable support for phosphide catalysts [2, 3, 10, 11]. For industrial usage, Al₂O₃ is a suitable support because it exhibits greater mechanical strength and
stability than SiO$_2$. Unfortunately, Al$_2$O$_3$ is not a suitable support for phosphide catalysts, because phosphate reacts with Al$_2$O$_3$ to form AlPO$_4$ [3, 6, 10, 11]. In fact, we have reported that the optimal reduction temperature (800 °C) for HDS activity of the Rh-P/Al$_2$O$_3$ catalyst is remarkably higher than that for HDS activity of the Rh-P/SiO$_2$ catalyst (550 °C) and that this higher temperature induces aggregation of Rh$_2$P [24, 27]. Therefore, we expect that high HDS activity can be obtained via the low-temperature synthesis of highly dispersed Rh$_2$P on an Al$_2$O$_3$ support.

Numerous reports have described the synthesis of phosphide catalysts at low temperatures. Teixeira da Silva et al. reported that the formation temperature of Ni$_2$P, which was prepared from a phosphate precursor, can be decreased by the addition of Pd [29]. Previously, we reported that the reduction temperature of phosphates on Al$_2$O$_3$ and SiO$_2$ substrates and the formation temperatures of Rh$_2$P were decreased by the addition of Na [30]. However, noble metal addition is not an appropriate method for the synthesis of noble metal phosphides, and added Na would decrease the catalytic activity. Thus, phosphite, which is more reducible than phosphate, has been used as a P precursor to form noble metal phosphides
However, phosphite on an Al₂O₃ support is less reducible than that on other supports [32]. Some P precursors without oxygen, such as phosphine (PH₃) and trioctylphosphine (TOP), have been reported [3, 12, 33, 34]. PH₃ easily reacts with metals to form phosphides at low temperatures; however, this reagent is highly toxic. TOP also reacts with metal precursors such as acetylacetonate complexes to form phosphides at lower temperatures. But this method requires a large amount of a P precursor. Furthermore, the washed phosphides were impregnated into Al₂O₃ to obtain the supported catalyst [35], which is a complicated method. On the other hand, some reports described synthesis of Ni₂P catalyst using triphenylphosphine ((C₆H₅)₃P, TPP) [36, 37], but this method was also carried out in trioctylamine solution under N₂ flow.

In our previous paper, we reported that rhodium and palladium phosphides were more easily formed using TPP compared with the corresponding phosphides prepared from phosphate, even in cases where the phosphides prepared from phosphate were calcined [25]. TPP is widely used as a ligand for homogeneous noble metal catalysts, indicating that TPP preferentially adsorbs onto noble metals rather than onto the
supporting substrates. In addition, we observed that the phosphates that interacted with noble metals were more easily reduced than those on supports [26]. We expect that Rh₂P would easily form on Al₂O₃ when TPP is used as a P precursor. In this study, the low-temperature synthesis of Rh₂P on Al₂O₃ using TPP was examined to enhance the HDS activity of this phosphide-based catalyst.

2. Experimental

2.1. Catalyst preparation

Alumina (Al₂O₃, BET surface area 101 m² g⁻¹) was supplied by Nippon Aerosil Co. The Rh/Al₂O₃ was prepared using an impregnation method. Rhodium (III) chloride trihydrate (RhCl₃·3H₂O, Kanto Chemical Co.) was used as an Rh precursor and was dissolved in water. The Rh loading was 5 or 10 wt%. After impregnation, the Rh/Al₂O₃ was dried at 110 °C for 24 h, followed by heat treatment under an N₂ stream at 450 °C for 1 h to decompose the Rh salt. The ramp rate for the N₂ treatment was 10 °C min⁻¹.

The TPP-added Rh/Al₂O₃ (P(T)/Rh/Al₂O₃) catalyst was also prepared
by an impregnation method. A TPP hexane solution was impregnated into Rh/Al$_2$O$_3$. The P loading was 1.5 or 3 wt%, and the P/Rh molar ratio in the catalysts was 1.0. The P(T)/Rh/Al$_2$O$_3$ catalyst was dried under an N$_2$ stream at 110 °C for 24 h to avoid oxidation of TPP. After drying, the catalyst was sieved into 30- to 42-mesh-size granules. The high-loading (Rh: 10 wt%, P: 3 wt%) catalyst was labeled as HL-P(T)/Rh/Al$_2$O$_3$.

2.2. Catalyst characterization

The P(T)/Rh/Al$_2$O$_3$ catalyst was characterized using temperature-programmed reduction (TPR), X-ray diffraction (XRD), X-ray photoelectron spectroscopy (XPS), transmission electron microscopy (TEM), and carbon monoxide (CO) adsorption analyses. TPR measurements were performed using a Shimadzu GC-8A gas chromatograph. The catalyst (0.1 g) was heated in a He stream (30 ml min$^{-1}$) from room temperature to 110 °C at 10 °C min$^{-1}$, followed by He treatment at 110 °C for 1 h. After this He treatment, the catalyst was cooled to 30 °C in a He stream, and the He was switched to a hydrogen–nitrogen (5 vol% H$_2$ in N$_2$) gas mixture at 30 °C for 0.5 h before the measurement. The TPR profile was recorded as the temperature was
increased from 30 °C to 850 °C at 10 °C min⁻¹; a thermal conductivity
detector (TCD) and a flame ionization detector (FID) were used to
monitor the H₂ consumption and the formation of hydrocarbons,
respectively. When a TPR profile was recorded by TCD, water was
removed using a molecular sieve trap. XPS spectra of the catalysts after
reduction were measured using a JEOL JPS-9010MX with Mg Kα
radiation (10 kV, 5 mA). Binding energy of measured spectra were
corrected using C 1s peak at 285.0 eV. The XRD patterns of the catalysts
were collected using a Rigaku MiniFlex equipped with a Cu-Kα radiation
source operated at 30 kV and 15 mA. TEM observations were carried out
using a JEOL JEM-2100F. The conditions of TEM operation were an
acceleration voltage of 200 kV and a magnification of 600000x. The
particle size distribution and average particle size were determined from
the measurements of 1000 particles in the TEM micrographs. The CO
uptake of the P(T)/Rh/Al₂O₃ catalysts was measured using the pulse
method. The P(T)/Rh/Al₂O₃ catalyst (0.1 g) was reduced under H₂ at
450 °C–750 °C for 1 h. CO was injected into the catalyst layer at 25 °C
using a sampling loop (1.0 ml). The CO uptake was measured with a
Shimadzu GC-8A gas chromatograph equipped with a TCD.

2.3. Hydrodesulfurization of thiophene

The HDS of thiophene was performed at 350 °C under 0.1 MPa using a conventional fixed-bed flow reactor. The P(T)/Rh/Al$_2$O$_3$ catalyst (0.1 g) was charged into the quartz reactor and heated (10 °C min$^{-1}$) under an H$_2$ stream (30 ml min$^{-1}$) at 450 °C–700 °C for 1 h. A hydrogen–thiophene gas mixture (H$_2$/C$_4$H$_4$S molar ratio = 30), obtained by passing an H$_2$ stream through a thiophene trap cooled at 0 °C, was then introduced into the reactor (W/F = 37.9 g h mol$^{-1}$). The reaction products were analyzed using a gas chromatograph equipped with a FID and silicone DC-550 (length: 2 m, temperature: 110 °C) and Al$_2$O$_3$/KCl plot (ID: 0.53 mm, length: 25 m, film thickness: 10 μm, temperature: 60 °C–190 °C, rate: 7.5 °C min$^{-1}$) columns.

The HDS rate constant was calculated from the following equation under the assumption of a pseudo-first-order reaction:

$$k_{HDS} = \frac{-\ln(1-x/100)}{W/F}$$ (1)

where $k_{HDS}$ is the reaction rate of thiophene HDS (mol h$^{-1}$ g$^{-1}$) and $x$ is the conversion at 3 h (%).
The turnover frequency (TOF) was calculated from the following equation:

\[ TOF = \frac{Fx/100}{WA} \]  

(2)

where \( F \) is the flow rate of thiophene (mol h\(^{-1}\)), \( W \) is the weight of catalyst loading (g), and \( A \) is the CO uptake (mol g\(^{-1}\)).

3. Results and Discussion

3.1. Low-temperature synthesis of Rh\(_2\)P on Al\(_2\)O\(_3\) supports

We have reported that the reduction temperature strongly affects the formation of Rh\(_2\)P catalysts [23-27]. Therefore, the TPR profiles of the P(T)/Rh/Al\(_2\)O\(_3\) catalyst were examined to clarify the reducibility of the rhodium oxide and TPP. **Figure 1** shows the TPR profile of the P(T)/Rh/Al\(_2\)O\(_3\) catalyst recorded by TCD and FID. Some peaks (at 120 °C, 180 °C, 225 °C, and 490 °C) appeared in the TPR profile recorded by TCD. In the TPR profile recorded by FID, peaks appeared at 165 °C and 230 °C, indicating that these peaks were attributable to the formation of hydrocarbons such as benzene and cyclohexane. However, no peaks were observed at 120 °C and 490 °C in this profile. Hwang et al. reported that
rhodium oxide interacting with Al\(_2\)O\(_3\) was reduced at 120 °C [38]. This result indicates that the peak at 120 °C was attributed to reduction of rhodium oxide interacted with Al\(_2\)O\(_3\). Oyama et al. reported that the peak of phosphine (PH\(_3\)) production appeared around 530 °C (800 K) in the TPR profile of Ni\(_2\)P/SiO\(_2\) precursor [7]. On the basis of these results, the peak at 490 °C is attributed to PH\(_3\) formation.

In the TPR profile of the Rh-P/Al\(_2\)O\(_3\) catalyst prepared from ammonium dihydrogen phosphate (Rh-P(A)/Al\(_2\)O\(_3\)), the hydrogen consumption, which was due to the reduction of AlPO\(_4\), was observed above 700 °C. In contrast, the reduction peak of TPP appeared at remarkably lower temperatures (approximately 200 °C) compared with that of AlPO\(_4\). Therefore, Rh\(_2\)P would be easily formed on Al\(_2\)O\(_3\) when TPP is used as a P source. Figure 2 shows the XRD patterns of P(T)/Rh/Al\(_2\)O\(_3\) catalysts after reduction. Irrespective of the reduction temperature, no peaks associated with Rh species were observed in the XRD patterns, indicating that Rh species were highly dispersed on the Al\(_2\)O\(_3\) support. Thus, we prepared the HL-P(T)/Rh/Al\(_2\)O\(_3\) catalyst (Rh: 10 wt%, P: 3 wt%) to evaluate the formation of Rh\(_2\)P.
The TPR profile of the HL-P(T)/Rh/Al₂O₃ catalyst is shown in Fig. 3. Peaks were observed at the same temperatures as those of the P(T)/Rh/Al₂O₃ catalyst (standard loading). This similarity indicates that loading does not affect the reducibility of the Rh and P species. Therefore, Rh₂P formation over Al₂O₃ support can be evaluated using the XRD patterns of the HL-P(T)/Rh/Al₂O₃ catalyst. The XRD patterns of the high-loading catalyst reduced at various temperatures are shown in Fig. 4. Furthermore, Fig. S1 shows the background (support) subtracted XRD patterns of the HL-P(T)/Rh/Al₂O₃ catalyst. After reduction at 350 °C, a broad peak for metallic Rh appeared around 41°. Furthermore, small peak also appeared at 47.2° and this peak would contain two peaks (Rh₂P: 46.7° and Rh: 47.8°). However, no peak for Rh₂P was observed at 32.6°. These results indicate that metallic Rh cores covered with Rh₂P shells would be formed. Above 450 °C, the intensity of the Rh₂P peaks increased, and that of the Rh peaks decreased. Moreover, the peak around 41° was hardly observed after reduction above 550 °C. Thus, Rh₂P would be completely formed on Al₂O₃ support by reduction with H₂ at 550 °C. In the case of the XRD pattern of the Rh-P(A)/Al₂O₃ catalyst, peaks for
Rh₂P were observed after the catalyst was reduced at temperatures above 750 °C [24, 27]. Thus, the formation temperature of Rh₂P can be remarkably decreased through the use of TPP as a P source.

3.2. Surface properties and particle size of Rh₂P on Al₂O₃

Figure 5 shows the XPS spectra of P(T)/Rh/Al₂O₃ catalyst after reduction. After reduction at any temperature, the peak for Rh 3d⁵/₂ appeared around 307.6 eV. Prins and Bussell reported that unsupported Rh₂P is metallic, which is consistent with observations for some other metal-rich phosphide phases (Ni₂P, Ni₃P, Cu₃P) [3, 28]. Furthermore, Rh 3d⁵/₂ peak at 307.6 eV can be attributed to Rh⁺⁺ [28]. Therefore, Rh in the P(T)/Rh/Al₂O₃ catalyst bears a partial positive charge. However, in the spectra of Rh-P(A)/Al₂O₃ catalyst reduced at 600 °C and 800 °C (Fig. S2), the peak for Rh 3d⁵/₂ was observed at lower binding energy (307.4 and 307.2 eV) than that in the spectra of P(T)/Rh/Al₂O₃ catalyst after reduction (307.6 eV). The binding energy of metallic Rh species appears at 307.0-307.2 eV [39, 40]. Thus, Rh in the P(T)/Rh/Al₂O₃ catalyst after reduction is more cationic than that in the Rh-P(A)/Al₂O₃ catalyst. In the
XPS spectra of P(T)/Rh/Al₂O₃ and Rh-P(A)/Al₂O₃ catalysts after reduction, the peaks for P 2pₓ/₂ were observed around 134.2-134.4 eV, which was attributed to phosphate species formed by exposing in air after reduction [28].

Table 1 shows the effect of the reduction temperature of P(T)/Rh/Al₂O₃ catalysts on their CO uptake. The maximum CO uptake was obtained in the case of the sample reduced at 600 °C. In the TPR profiles of the P(T)/Rh/Al₂O₃ catalyst recorded by TCD and FID (Fig. 1), the peak corresponding to PH₃ formation was observed at 490 °C. These results indicate the following: At lower reduction temperatures (below 450 °C), excess P (P/Rh = 1.0) covers exposed Rh sites on Rh₂P. In the TPR profile, hydrogen consumption peak for PH₃ formation was observed at 490 °C, as shown in Fig. 1. Because excess P adsorbed onto Rh₂P reacts with H₂ to form PH₃, CO uptake increased with increasing reduction temperature, when the reduction temperature was less than 600 °C. At reduction temperatures above 600 °C, the CO uptake gradually decreased with increasing temperature.

TEM images of the P(T)/Rh/Al₂O₃ catalysts after reduction are shown
in Fig. 6. Highly dispersed particles are evident in all of the micrographs.

The particle size of the Rh species appeared to remain unchanged after reduction at 650 °C. Figure 7 shows the particle size distribution of P(T)/Rh/Al₂O₃ catalysts after reduction, as calculated from TEM images. With increasing reduction temperature, the particle size distribution shifted to larger particle diameters. The particle distribution for the P(T)/Rh/Al₂O₃ catalyst before reduction exhibited a substantially sharp peak compared to that for the Rh-P(A)/Al₂O₃ catalyst (Fig. S3). The average particle size slightly increased with increasing reduction temperature (Table 1). Therefore, decrease of CO uptake above 600 °C can be explained by sintering of Rh₂P particles. Before reduction, the average particle size of the P(T)/Rh/Al₂O₃ catalyst (0.97 nm) was smaller than that of the Rh-P(A)/Al₂O₃ catalyst (2.60 nm, Fig. S3). Furthermore, the crystallite size of the Rh-P(A)/Al₂O₃ catalyst after reduction at 750 °C–850 °C was 5.3–8.5 nm (as calculated from its XRD pattern using the Scherrer equation) [24]. These results indicate that the particle size of the P(T)/Rh/Al₂O₃ catalyst was remarkably smaller than that of the Rh-P(A)/Al₂O₃ catalyst. After impregnation, RhCl₃ reacted with Al-OH to
form $\text{Rh}^{3+} - \text{O} - \text{Al}$ species [41]. However, phosphate preferentially reacts with $\text{Al}_2\text{O}_3$ to form $\text{AlPO}_4$ [3, 6, 10, 11], resulting in the Rh species not interacting with the $\text{Al}_2\text{O}_3$ surface. Furthermore, when phosphate was used as a P source, the particle size of the Rh species increased with increasing P loading [26]. On the basis of these results, highly dispersed $\text{Rh}_2\text{P}$ particles can be obtained by sequential impregnation using TPP as a P source.

3.3. Hydrodesulfurization of thiophene over the P(T)/Rh/Al$_2$O$_3$ catalyst

Figure 8 shows the HDS of thiophene over P(T)/Rh/Al$_2$O$_3$ catalyst reduced at 450-700 °C. In the P(T)/Rh/Al$_2$O$_3$ catalysts after reduction at lower temperatures (below 550 °C), the HDS conversion decreased with time on stream. On the other hand, the P(T)/Rh/Al$_2$O$_3$ catalysts reduced at higher temperatures (above 600 °C) showed stable HDS conversion. This stability was the same as that of Rh-P(A)/Al$_2$O$_3$ catalyst reduced at higher temperature (800 °C), as shown in Fig. S4.

The effect of reduction temperature on the HDS rate ($k_{\text{HDS}}$) of the
P(T)/Rh/Al₂O₃ catalyst after reaction for 3 h are listed in Table 2. The HDS rate of the catalyst remarkably increased as the reduction temperature was increased to 650 °C. In our papers, it was found that Rh₂P formation enhances HDS activity of Rh-P catalyst [23-27, 30]. After reduction at 450 °C, Rh₂P were observed in the XRD pattern of the P(T)/Rh/Al₂O₃ catalyst (Figs. 4 and S1). Furthermore, CO uptake increased with increasing reduction temperature from 450 °C to 600 °C, as shown in Table 1. Therefore, the enhancement of $k_{HDS}$ can be explained by Rh₂P formation and elimination of excess P on Rh₂P. However, the optimal reduction temperature for maximum $k_{HDS}$ was 650 °C, which is slightly higher than the temperature corresponding to maximum CO uptake (Table 1). In the XPS spectra, binding energy of Rh 3d₅/₂ hardly changed with increasing reduction temperature from 450 °C to 650 °C, as shown in Fig. 5. These results indicate that the difference in the optimal reduction temperatures for $k_{HDS}$ and CO uptake cannot be explained by the electric state of Rh. In the case of the RuS₂/Al₂O₃ catalyst, pyrite-structured RuS₂ exhibited higher catalytic activity than amorphous RuS₂ for thiophene HDS [42]. Recently, it has been reported that particle
size strongly affects the crystallinity of Pt nanoparticles [43]. The disordered Rh particle habit persists to 4–5 nm; this value is substantially greater than that for Pt particles (2–3 nm) [44]. In the present study, because the particle size of Rh$_2$P on Al$_2$O$_3$ (after reduction at 450 °C) was ca. 1.2 nm (Table 1), the P(T)/Rh/Al$_2$O$_3$ catalyst should contain amorphous and/or low-crystallinity Rh$_2$P particles. When the reduction temperature exceeded 600 °C, even though the CO uptake decreased, the crystallinity of Rh$_2$P increased. Because the crystallinity of Rh$_2$P affects HDS activity and stability, the optimal reduction temperature for $k_{HDS}$ was higher than that for CO uptake.

The maximum $k_{HDS}$ of P(T)/Rh/Al$_2$O$_3$ catalyst (38.5 mmol g$^{-1}$ h$^{-1}$) was 1.8 times higher than that of Rh-P(A)/Al$_2$O$_3$ catalyst (20.9 mmol g$^{-1}$ h$^{-1}$, Table S1). High activity of the P(T)/Rh/Al$_2$O$_3$ catalyst can be explained by formation of highly dispersed Rh$_2$P particles using TPP as a P source.

The optimal reduction temperature for maximum $k_{HDS}$ of the P(T)/Rh/Al$_2$O$_3$ catalyst (650 °C) was 150 °C lower than that for maximum $k_{HDS}$ of the Rh-P(A)/Al$_2$O$_3$ catalyst (800 °C) [24, 27]. This result is explained by Rh$_2$P being formed at a lower reduction temperature when
TPP is used as the P source. At temperatures above 650 °C, the HDS rate of the P(T)/Rh/Al₂O₃ catalyst decreased. The average particle size of the P(T)/Rh/Al₂O₃ catalyst slightly increased with increasing reduction temperature, as shown in Table 1. Thus, the decrease of HDS rate was due to sintering of Rh₂P particles.

The HDS reaction products were butanes, butenes, tetrahydrothiophene (THT), and trace amounts of cracking products. The selectivities for these reaction products in the thiophene HDS reaction over the P(T)/Rh/Al₂O₃ catalyst is listed in Table 2. Because the selectivities depend on the thiophene conversion rate, the product selectivities should be evaluated at similar thiophene conversion rates. At higher reduction temperatures (above 600 °C), the same thiophene conversion rate was obtained. The selectivity for THT increased with increasing reduction temperature. At similar conversion rates (ca. 53%), the P(T)/Rh/Al₂O₃ catalyst (reduced at 600 °C) exhibited remarkably higher butane selectivity and lower THT selectivity compared to those obtained with the Rh-P(A)/Al₂O₃ catalyst reduced at 800 °C (Table S2). TEM observations revealed that average particle size of P(T)/Rh/Al₂O₃ catalyst increased with increasing
reduction temperature. However, these particle sizes (Table 1) were remarkably smaller than that in the Rh-P(A)/Al₂O₃ catalyst (Fig. S3). These results indicate that small Rh₂P particles exhibit higher hydrogenation and C–S bond-cleavage abilities than larger particles. The selectivity of THT over Rh-P/SiO₂ catalyst increased with decreasing W/F [26]. Furthermore, the Rh₂P/SiO₂ catalyst strongly favored hydrogenation pathway [28]. Therefore, thiophene mainly reacts via hydrogenation route over the P(T)/Rh/Al₂O₃ catalyst with small Rh₂P particle.

3.4. Turnover frequency of the P(T)/Rh/Al₂O₃ catalyst

Table 2 also shows the turnover frequency (TOF) of the P(T)/Rh/Al₂O₃ catalysts reduced at various temperatures, which were calculated from CO uptake (assuming CO/Rh = 1). The TOFs of the P(T)/Rh/Al₂O₃ catalysts, which were significantly greater than that of the Rh/Al₂O₃ catalyst (15.9 h⁻¹, Table S1), increased as the reduction temperature was increased from 450 °C to 650 °C. These results imply that the formation and crystallinity of Rh₂P positively affected the TOF. However, the TOF of the P(T)/Rh/Al₂O₃ catalyst reduced at 650 °C (113.2 h⁻¹) was substantially
lower than that of the Rh-P(A)/Al₂O₃ catalyst (271.9 h⁻¹, Table S1). The XPS results (Figs. 4 and S1) revealed that the state of Rh in the P(T)/Rh/Al₂O₃ catalyst is more cationic than that of Rh-P(A)/Al₂O₃ catalyst. Furthermore, small Rh₂P particles in the P(T)/Rh/Al₂O₃ catalyst would be amorphous and/or poorly crystalline, as described above. Thus, the low TOF of the P(T)/Rh/Al₂O₃ catalyst is explained by the existence of cationic and/or low crystalline Rh₂P particles. In the HDS of thiophene at 370 °C, the Ni₂P/SiO₂ (P/Ni = 0.8) catalyst exhibited a TOF of 61 h⁻¹ (0.017 s⁻¹) [19]. The TOF of the P(T)/Rh/Al₂O₃ catalyst reduced at 650 °C (113.2 h⁻¹) was higher than that of the Ni₂P/SiO₂ catalyst.

4. Conclusions

The low-temperature synthesis of Rh₂P using TPP as a P source and its catalytic activity toward the HDS reaction were investigated. Because TPP was easily reduced under H₂, Rh₂P was formed on Al₂O₃ supports at lower temperatures than Rh₂P formed from a phosphate precursor. The characterization results revealed the following: After reduction at lower temperature (below 450 °C), excess P covered the surface of Rh₂P.
the reduction temperature was increased to 600 °C, excess P covering
Rh$_2$P surface were reduced to the active Rh$_2$P phase. Furthermore, the
average particle size of Rh$_2$P prepared from TPP was approximately 1.2
nm; this particle size was remarkably smaller than that of Rh$_2$P prepared
from phosphate. The P(T)/Rh/Al$_2$O$_3$ catalyst exhibited maximal $k_{HDS}$ after
reduction at 650 °C, and this activity was 1.8 times higher than that of the
Rh-P(A)/Al$_2$O$_3$ catalyst reduced at 800 °C. Thus, the high HDS rate of the
P(T)/Rh/Al$_2$O$_3$ catalyst was caused by small Rh$_2$P particles formed at
lower reduction temperatures.

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References


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Captions

Figure 1  TPR profiles of P(T)/Rh/Al₂O₃ catalyst recorded by TCD and FID.

Figure 2  XRD patterns of P(T)/Rh/Al₂O₃ catalyst reduced at 450 °C–650 °C.

Figure 3  XRD patterns of HL-P(T)/Rh/Al₂O₃ catalyst reduced at 350 °C–650 °C.

Figure 4  XPS spectra of P(T)/Rh/Al₂O₃ catalyst reduced at 450 °C–650 °C.

Figure 5  Relationship between the reduction temperature and CO uptake of P(T)/Rh/Al₂O₃ catalyst.

Figure 6  TEM images of P(T)/Rh/Al₂O₃ catalyst (A) before and after reduction at (B) 450 °C, (C) 550°C, and (D) 650 °C.

Figure 7  Particle size distribution of P(T)/Rh/Al₂O₃ catalyst (A) before and after reduction at (B) 450 °C, (C) 550°C, and (D) 650 °C.

Figure 8  HDS of thiophene over P(T)/Rh/Al₂O₃ catalyst after reduction at 450-700 °C.
Table 1 CO uptake and average particle size calculated from TEM images of P(T)/Rh/Al₂O₃ catalyst before and after reduction.

<table>
<thead>
<tr>
<th>Reduction temperature (°C)</th>
<th>CO uptake (μmol g⁻¹)</th>
<th>Average particle size (nm)</th>
</tr>
</thead>
<tbody>
<tr>
<td>Before reduction</td>
<td>-</td>
<td>0.97</td>
</tr>
<tr>
<td>450</td>
<td>91.6</td>
<td>1.18</td>
</tr>
<tr>
<td>500</td>
<td>142.3</td>
<td>-</td>
</tr>
<tr>
<td>550</td>
<td>171.5</td>
<td>1.25</td>
</tr>
<tr>
<td>600</td>
<td>188.1</td>
<td>-</td>
</tr>
<tr>
<td>650</td>
<td>178.7</td>
<td>1.31</td>
</tr>
<tr>
<td>700</td>
<td>165.7</td>
<td>-</td>
</tr>
</tbody>
</table>
Table 2 HDS properties of P(T)/Rh/Al₂O₃ catalyst. Reaction conditions: H₂/C₄H₄S = 30, total pressure = 0.1 MPa.

<table>
<thead>
<tr>
<th>Reduction temperature (°C)</th>
<th>W/F (g h mol⁻¹)</th>
<th>Thiophene conversion (%)</th>
<th>k₈DS (mmol g⁻¹ h⁻¹)</th>
<th>TOF (h⁻¹)</th>
<th>Selectivity of HDS products (%)</th>
</tr>
</thead>
<tbody>
<tr>
<td></td>
<td></td>
<td></td>
<td></td>
<td></td>
<td>C₁-C₃₄ Butanes Butenes THTb</td>
</tr>
<tr>
<td>450</td>
<td>37.9</td>
<td>27.4</td>
<td>8.5</td>
<td>79.0</td>
<td>0.6 37.8 60.5 1.0</td>
</tr>
<tr>
<td>500</td>
<td>37.9</td>
<td>47.9</td>
<td>17.3</td>
<td>88.9</td>
<td>0.7 46.3 51.8 1.2</td>
</tr>
<tr>
<td>550</td>
<td>37.9</td>
<td>63.0</td>
<td>26.2</td>
<td>96.7</td>
<td>0.7 50.6 47.7 1.0</td>
</tr>
<tr>
<td>600</td>
<td>37.9</td>
<td>72.5</td>
<td>34.0</td>
<td>101.6</td>
<td>0.6 53.1 45.4 0.9</td>
</tr>
<tr>
<td>650</td>
<td>37.9</td>
<td>76.7</td>
<td>38.5</td>
<td>113.2</td>
<td>0.4 52.5 46.2 0.9</td>
</tr>
<tr>
<td>700</td>
<td>37.9</td>
<td>70.9</td>
<td>32.7</td>
<td>112.9</td>
<td>0.4 41.4 56.6 1.6</td>
</tr>
<tr>
<td>600</td>
<td>26.5</td>
<td>52.9</td>
<td>28.4</td>
<td>106.1</td>
<td>0.9 42.3 55.0 1.7</td>
</tr>
</tbody>
</table>

a C₁-C₃ hydrocarbons

b Tetrahydrothiophene
Fig. 1
Fig. 2
Fig. 3
Fig. 4
Fig. 5
Fig. 7
Conversion (%)

Time on stream (h)

Reduction temperature
- 450 °C
- 550 °C
- 650 °C
- 500 °C
- 600 °C
- 700 °C

Fig. 8
Graphical abstract

• Conventional preparation of Rh$_2$P/Al$_2$O$_3$

  Reduction at 800 °C

• New preparation of Rh$_2$P/Al$_2$O$_3$

  Reduction at 650 °C

  High activity!